

An Ultra High Ruggedness InGaP/GaAs HBT for Multi-Mode / Multi-Band Power Amplifier Application

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Abstract

InGaP/GaAs HBT technology has been widely used in power amplifier (PA) design for wireless communications due to its high linearity and high efficiency. In recent years Multi-Mode / Multi-Band (MMMB) power amplifier architecture has emerged as the dominant trend with the strong growth of the smart phone. Integrated 4G MMMB solutions need to support GSM, UMTS and LTE schemes. One of the requirements for the GSM PA is HBT ruggedness, with the ability to maintain peak performance under the stress of high voltage standing wave ratio (VSWR) mismatch. We present an ultra high ruggedness HBT technology (Fig. 1) that can sustain a VSWR mismatch of 50:1 without trading off RF performance. We introduce both horizontal and vertical emitter finger orientations for added flexibility of device layout (Table 1 and Fig. 2). In addition to our conventional Type A HBT we also introduce an improved transistor layout with higher maximum available gain (Table 2 and Fig 3).

This work demonstrates an ultra high ruggedness HBT which survives VSWR 50:1 ruggedness testing at $V_{CE} = 5V$ without performance degradation (Table 4). If VSWR is kept at 10:1 and sweeping VCE operation voltage, this technology survives $V_{CE} = 7V$. Compared to the reference sample this work shows a 2 volt VCE improvement, in line with the requirements for GSM application (Table 5). Furthermore, we present our new Type-B HBTs with higher gain performance and a layout solution which makes it easier for the designer to realize a MMMB PA in a single InGaP/GaAs HBT chip.

